

AZ 125nXT – run sheet

Merck

[nanyte.com/photoresists/az-125nxt](https://www.merck.com/content/az-125nxt) · last updated 2026-07-26

Thickness: 18–120 µm

Softbake: 115–140 °C · 5–20 min

Develop: Developer AZ 300MIF · Dilution 0.26N (2.38%) TMAH, ready-to-use; puddle mode recommended · Method puddle

Hardbake: 130–140 °C